

Nanocarbon technologies to achieve large-scale production

Carbon nanotube Carbon nanohorn aggregate Carbon nanobrush

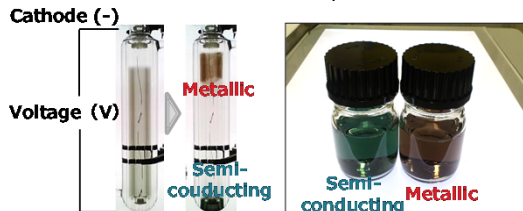
- Semiconducting CNT ink for thin film transistor application was developed.
- Mass production technique of CNHs was developed and the product is on sale.
- Continuous preparation technology of carbon nanobrushes was developed.

Carbon nanotube (CNT)

□ Separation technology of metallic- and semi-conducting CNT for thin film transistor application

➤ Electric-field-induced layer formation (ELF)

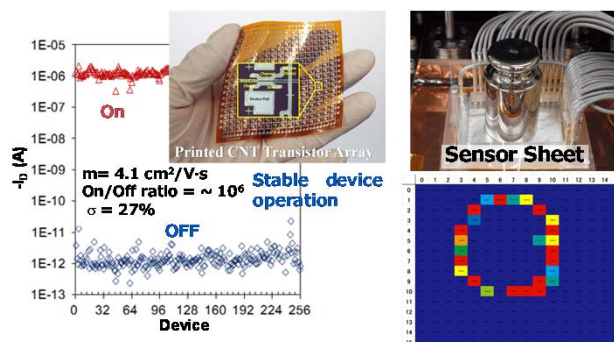
- ✓ Semi-conducting CNT of above 99%
- ✓ Non-ionic surfactant: stable operation of device



K. Ihara, et. al, J. Phys. Chem. C, 2011.

Application technology

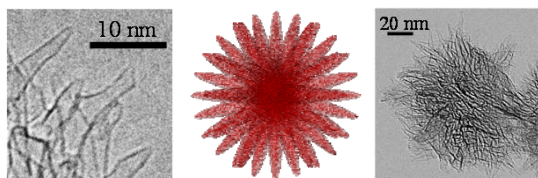
□ Printed CNT transistor array with CNT ink



H. Numata, et. al, IEEE NANO 2016.

Carbon nanohorn aggregate

- Uniform particle size
- Large surface area
- High dispersibility
- High purity · Safety
- Incorporation of various materials

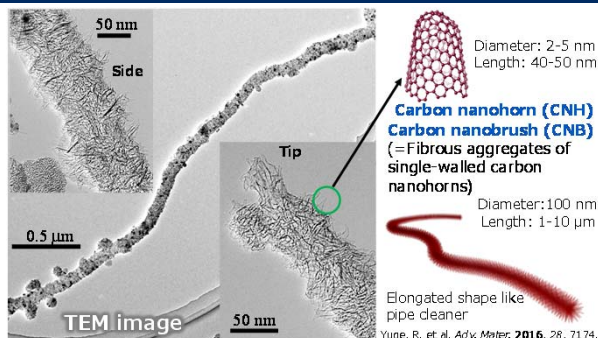


Application technology

- Production rate of 100g/h (1kg/day)
 - Application for energy and medical field
- Large scale manufacturing equipment

	CNHs	Hole-opening CNHs
Purity	10%	90% (Graphite, a-C)
Surface area	400 m²/g	1400 m²/g
Dispersibility	Hydrophobic	Hydrophilic
Conductivity	1.3 S/cm	1.2 S/cm

Carbon nanobrush (CNB)



Application technology

- Establishment of production method of 10g/day
- Potential application for IoT and energy device

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